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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/552,728	10/11/2005	Koso Fujino	017700-0179 9461	
23392 FOLEY & LAR	7590 05/11/201 RDNER	EXAMINER		
555 South Flow SUITE 3500		WARTALOWICZ, PAUL A		
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			1793	
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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

		Application N	o.	Applicant(s)			
Office Action Summary		10/552,728		FUJINO ET AL.			
		Examiner		Art Unit			
		PAUL A. WAR	ΓALOWICZ	1793			
The MAILING DATE o Period for Reply	f this communication ap	pears on the cov	er sheet with the c	orrespondence ac	ddress		
A SHORTENED STATUTOR WHICHEVER IS LONGER, - Extensions of time may be available to after SIX (6) MONTHS from the mailing of the precise of th	FROM THE MAILING D inder the provisions of 37 CFR 1.7 ng date of this communication. ve, the maximum statutory period ded period for reply will, by statut- than three months after the mailin	DATE OF THIS ( 136(a). In no event, ho will apply and will expi ee, cause the application	COMMUNICATION wever, may a reply be time or SIX (6) MONTHS from to become ABANDONEI	I. lely filed the mailing date of this of (35 U.S.C. § 133).			
Status							
2a)⊠ This action is <b>FINAL</b> .  3)□ Since this application	nication(s) filed on <u>19 /</u> 2b)∏ This is in condition for allowa with the practice under /	s action is non-f ance except for f	ormal matters, pro		e merits is		
Disposition of Claims							
5) □ Claim(s) □ is/are 6) □ Claim(s) 3.6,9,12 and 7) □ Claim(s) □ is/are 8) □ Claim(s) □ are su  Application Papers  9) □ The specification is obj 10) □ The drawing(s) filed or  Applicant may not reque	(s) is/are withdra allowed. 15-22 is/are rejected. objected to. bject to restriction and/of ected to by the Examina is/are: a) access that any objection to the	er. cepted or b) □ cepted drawing(s) be he	rement. bjected to by the E	e 37 CFR 1.85(a).	ED 1 121/d)		
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority under 35 U.S.C. § 119							
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>							
Attachment(s)  1) Notice of References Cited (PTO- 2) Notice of Draftsperson's Patent D 3) Information Disclosure Statement Paper No(s)/Mail Date 1/29/10.	rawing Review (PTO-948)	4) [ 5) [ 6) [	Interview Summary Paper No(s)/Mail Da Notice of Informal P Other:	te			

## **DETAILED ACTION**

## Response to Arguments

Applicant's arguments with respect to claims 3, 6, 9, 12, 15-22 have been considered but are moot in view of the new ground(s) of rejection.

Applicant argues that none of Eyidi, Goyal, '750, Hsu, Akedo, or Hans teaches the annealing temperature of claims 3 and 9. However, none of these references are relied upon to teach the annealing temperature. In response to applicant's arguments against the references individually, one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references. See *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); *In re Merck & Co.*, 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986).

Christen is relied upon to teach the annealing temperature and atmosphere of claims 3, 9, 19-22 as described in the rejection below.

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

1. Determining the scope and contents of the prior art.

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2. Ascertaining the differences between the prior art and the claims at issue.

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- 3. Resolving the level of ordinary skill in the pertinent art.
- 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

Claims 3, 9, 15-22 are rejected under 35 U.S.C. 103(a) as being unpatentable over Eyidi et al. ("Growth of CeO<sub>2</sub> thin films…") in view of Hans Thieme et al. (US 6458223) and JP 07-105750 (hereinafter '750: please refer to the machine translation attached to this office action) and Hsu (US 6569745) and Christen (US 6296701).

Eyidi teaches a method of making a superconducting (pg 15) wherein nickel substrates are hot rolled and then hot rolled, cold rolled to achieve a certain deformation (this appears to be a planarizing step), annealed, cleaned wherein after cleaning an intermediate layer of CeO<sub>2</sub> is deposited therein, wherein a YBCO superconductor is disposed thereon (pg 20).

Eyidi fails to teach the planarizing depth, the crystal axis offset, and the surface roughness.

'750 teaches a superconductor wire [0001] wherein the angle  $\Phi$  (made by the normal X of the crystal surface and the Y of the polycrystalline metal base body) is less than 15° and angle  $\theta$  formed by connecting crystal particles is less than 10° (Abstract, [0023]) for the purpose of reducing micro unevenness of the grain boundary [0023].

Therefore, it would have been obvious to one of ordinary skill in the art at the time applicant's invention was made to provide a substrate having an angle  $\Phi$  (made by the normal X of the crystal surface and the Y of the polycrystalline metal base body) is less than 15° and angle  $\theta$  formed by connecting crystal particles is less than 10°

(Abstract, [0023]) in Eyidi in order to reduce micro unevenness of the grain boundary [0023] as taught by '750.

It appears that the angles disclosed in '750, namely that the angle  $\Phi$  (made by the normal X of the crystal surface and the Y of the polycrystalline metal base body) is less than 15° and angle  $\theta$  formed by connecting crystal particles is less than 10° (Abstract, [0023]) overlaps with and inherently meets the limitation of crystal axis offset relative to an orientation axis by at most 10°.

If '750 does not inherently teach a crystal axis offset relative to an orientation axis by at most 10°, it would be obvious to reduce the crystal axis offset relative to an orientation axis to overlap with a range of at most 10° because '750 teaches that reducing micro unevenness of the grain boundary is desired for superconductor properties [0023].

Hans Thieme et al. teach a method of making a superconductor (col. 1) wherein the roughness of the substrate corresponds to the current carrying capability of the superconductor film wherein the roughness is 10-20 nm Ra (col. 11-12).

Therefore, it would have been obvious to one of ordinary skill in the art at the time applicant's invention was made to provide a roughness of 10-20 nm Ra (col. 11-12) for the metal substrate in Eyidi in order to maintain a certain current carrying capability of the superconductor film (col. 11-12) as taught by Hans Thieme et al.

Hsu teaches a method of making a superconducting article (col. 1) wherein it is known to planarize a layer to a thickness of between 50-500 nm (col. 2).

Therefore, it would have been obvious to one of ordinary skill in the art to planarize a layer to a thickness of between 50-500 nm (col. 2) in Eyidi in order to produce a superconducting article as taught by Hsu.

Eyidi teaches that the metal substrate is cleaned (page 15), but fails to teach thermally treating said textured metal substrate at a temperature of 500-800°C, more preferably 600-700°C, in either a vacuumed or reduced atmosphere at least once.

Christen, however, teaches a method of making biaxial substrates for superconductors (col. 1, lines 14-18) wherein a nickel substrate is annealed in a vacuum atmosphere, or reducing atmosphere, at a temperature of 600-900°C for 5 hours for the purpose of removing metallic oxides and other impurities (col. 8, lines 16-30).

Therefore, it would have been obvious to one of ordinary skill in the art at the time applicant's invention was made to provide annealing the nickel substrate of Eyidi in a vacuum atmosphere, or reducing atmosphere, at a temperature of 600-900°C for 5 hours in order to remove metallic oxides and other impurities (col. 8, lines 16-30) as taught by Christen and because Eyidi teaches cleaning the substrates before depositing the cerium oxide layer (page 15).

Regarding claims 19 and 20, it appears that the range of annealing temperature disclosed by Christen overlaps with that of claims 19 and 20. In the case where the claimed ranges "overlap or lie inside ranges disclosed by the prior art" a prima facie case of obviousness exists. MPEP 2144.05 (I).

Regarding claim 21, Christen teaches that the atmosphere for cleaning is a vacuumed atmosphere (col. 8, lines 20-25). The range of pressure of less than 1 atm (equivalent to 1.01 \* 10<sup>5</sup> Pa) taught by Christen overlaps with the claimed range of less than 1.33 \* 10<sup>2</sup> Pa. In the case where the claimed ranges "overlap or lie inside ranges disclosed by the prior art" a prima facie case of obviousness exists. MPEP 2144.05 (I).

Claims 6, 12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Eyidi et al. ("Growth of CeO<sub>2</sub> thin films...") in view of Hans Thieme et al. (US 6458223) and JP 07-105750 (hereinafter '750: please refer to the machine translation attached to this office action) and Hsu (US 6569745) and Christen (US 6296701) and Akedo et al. (US 6827634).

Eyidi teach a method of making a superconductor as described above in claim 3. Eyidi teaches rolling the substrate (pg 15).

Akedo teaches a method for depositing a layer on a substrate (col. 1) wherein it is known to use a mirror roller for the purpose of planarizing a material layer (col. 5).

Therefore, it would have been obvious to one of ordinary skill in the art at the time applicant's invention was made to provide a mirror roller in Eyidi in order to carry out planarization as taught by Akedo et al.

## Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP

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§ 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to PAUL A. WARTALOWICZ whose telephone number is (571)272-5957. The examiner can normally be reached on 8:30-6 M-Th and 8:30-5 on Alternate Fridays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Stanley Silverman can be reached on (571) 272-1358. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Paul Wartalowicz May 7, 2010

/Stanley Silverman/ Supervisory Patent Examiner, AU 1793